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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|-----------------|-------------|----------------------|---------------------|------------------|
| 09/928,247      | 08/10/2001  | Patrick W. Mullen    | 1571.2020-001       | 5637             |

21005 7590 01/18/2005

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EXAMINER

VARGOT, MATHIEU D

| ART UNIT | PAPER NUMBER |
|----------|--------------|
|----------|--------------|

1732

DATE MAILED: 01/18/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

|                        |                                      |   |  |
|------------------------|--------------------------------------|---|--|
| <b>Advisory Action</b> | <b>Application No.</b><br>09/928,247 | <b>Applicant(s)</b><br>MULLEN, PATRICK W. |  |
|                        | <b>Examiner</b><br>Mathieu D. Vargot | <b>Art Unit</b><br>1732                   |  |

**--The MAILING DATE of this communication appears on the cover sheet with the correspondence address --**

THE REPLY FILED 27 December 2004 FAILS TO PLACE THIS APPLICATION IN CONDITION FOR ALLOWANCE. Therefore, further action by the applicant is required to avoid abandonment of this application. A proper reply to a final rejection under 37 CFR 1.113 may only be either: (1) a timely filed amendment which places the application in condition for allowance; (2) a timely filed Notice of Appeal (with appeal fee); or (3) a timely filed Request for Continued Examination (RCE) in compliance with 37 CFR 1.114.

**PERIOD FOR REPLY** [check either a) or b)]

- a) ☒ The period for reply expires 3 months from the mailing date of the final rejection.  
b) ☐ The period for reply expires on: (1) the mailing date of this Advisory Action, or (2) the date set forth in the final rejection, whichever is later. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of the final rejection.  
**ONLY CHECK THIS BOX WHEN THE FIRST REPLY WAS FILED WITHIN TWO MONTHS OF THE FINAL REJECTION. See MPEP 706.07(f).**

Extensions of time may be obtained under 37 CFR 1.136(a). The date on which the petition under 37 CFR 1.136(a) and the appropriate extension fee have been filed is the date for purposes of determining the period of extension and the corresponding amount of the fee. The appropriate extension fee under 37 CFR 1.17(a) is calculated from: (1) the expiration date of the shortened statutory period for reply originally set in the final Office action; or (2) as set forth in (b) above, if checked. Any reply received by the Office later than three months after the mailing date of the final rejection, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

1. ☐ A Notice of Appeal was filed on \_\_\_\_\_. Appellant's Brief must be filed within the period set forth in 37 CFR 1.192(a), or any extension thereof (37 CFR 1.191(d)), to avoid dismissal of the appeal.  
2. ☐ The proposed amendment(s) will not be entered because:  
(a) ☐ they raise new issues that would require further consideration and/or search (see NOTE below);  
(b) ☐ they raise the issue of new matter (see Note below);  
(c) ☐ they are not deemed to place the application in better form for appeal by materially reducing or simplifying the issues for appeal; and/or  
(d) ☐ they present additional claims without canceling a corresponding number of finally rejected claims.

NOTE: \_\_\_\_\_.

3. ☐ Applicant's reply has overcome the following rejection(s): \_\_\_\_\_.  
4. ☐ Newly proposed or amended claim(s) \_\_\_\_\_ would be allowable if submitted in a separate, timely filed amendment canceling the non-allowable claim(s).  
5. ☒ The a) ☐ affidavit, b) ☐ exhibit, or c) ☒ request for reconsideration has been considered but does NOT place the application in condition for allowance because: See Continuation Sheet.  
6. ☐ The affidavit or exhibit will NOT be considered because it is not directed SOLELY to issues which were newly raised by the Examiner in the final rejection.  
7. ☒ For purposes of Appeal, the proposed amendment(s) a) ☐ will not be entered or b) ☒ will be entered and an explanation of how the new or amended claims would be rejected is provided below or appended.

The status of the claim(s) is (or will be) as follows:


Claim(s) allowed: NONE.

Claim(s) objected to: NONE.

Claim(s) rejected: 15-21, 23-29 and 31-34.

Claim(s) withdrawn from consideration: 1-14, 22 and 30.

8. ☐ The drawing correction filed on \_\_\_\_\_ is a) ☐ approved or b) ☐ disapproved by the Examiner.  
9. ☐ Note the attached Information Disclosure Statement(s) (PTO-1449) Paper No(s). \_\_\_\_\_.  
10. ☒ Other: See Continuation Sheet

  
Mathieu D. Vargot  
Primary Examiner  
Art Unit: 1732

Continuation of 5. does NOT place the application in condition for allowance because: Japanese -375 discloses the basic claimed method and device, with Martens providing what is considered to be obvious and within the skill level concerning--1) making a process continuous (the limitation of material passing the radiation source in claims 15 and 27) and 2) the structure that would allow the radiation to pass through the base (ie, the recitation that the base is between the material and the pattern in claim 23).

Continuation of 10. Other: Applicant's request for reconsideration has been considered but is not persuasive. Certainly, one of ordinary skill in the art would gleam from Martens that a radiation curing process would be made continuous and hence method claims 15 and 27 and their dependents are submitted to have been obvious over the combination. Applicant appears to be arguing the references separately when the rejection is based on the combination. Also, one would understand from Martens that transparent bases are used in radiation curing devices and that the placement of the pattern would have obviously been between the base and the material to be cured in Japanese -375.



MATHIEU D. VARGOT  
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GROUP 1300

1/13/05